

IP and Patent Seminar



Mining, Obtaining and Managing Patents in the US and Abroad

Speaker:	Mr. Michael Stein , Stein IP LLC, USA
Date:	3 Jun 2016, Friday
Time:	14:00 - 16:00
Venue:	Rm 508, 5/F, Photonics Centre, 2 Science Park East Avenue, Hong Kong Science Park, Shatin, Hong Kong
Language:	English
Online Registration:	http://www.astri.org/registration-form/?pid=17976

Speaker's Biography



Michael Stein graduated from the University of Pennsylvania majoring in Electrical Engineering in 1987 and worked as a systems analyst on missile guidance systems for two years. During part of his time earning his law degree, Mr. Stein performed patent searches in the Patent and Trademark Office. He has been actively involved in the preparation and prosecution of U.S. patent applications in many different areas of technology, as well as counseling with clients extensively with regard to other intellectual property matters, including patent portfolio management, risk assessment and trademarks. He founded his firm, STEIN IP LLC, in 2004 in Washington D.C. The firm currently has eight patent attorneys and patent agents, along with another IP attorney. He has also participated in seminars and activities of the Asia Pacific Lawyers Association and the Asian Patent Attorneys Association, and has traveled extensively throughout Japan and other parts of Asia as well.

Abstract

This seminar will be divided into 3 general topics: (1) mining for patents; (2) obtaining patents; and (3) managing patents and patent portfolios.

In section 1, the materials and discussion will cover ways to search for inventions and discover potential ideas within an organization.

In section 2, the materials and discussion will cover advice and tips for drafting and prosecuting patents.

In section 3, the materials and discussion will cover techniques for taking care of patents and managing patent portfolios to maximize value and assist the organization in reaching its goals.

The seminar is intended to be interactive, with participation by attendees strongly encouraged. Focus will be given to specific areas requested by attendees.